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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/993,824	11/06/2001	Andreas Wittman	476-2024.1	8714
75	590 07/16/2003	•		• ,
Mark D. Saralino, Esq.			EXAMINER	
Renner, Otto, Boisselle & Sklar 1621 Euclid Avenue			NGUYEN, DUNG T	
19th Floor Cleveland, OH 44115			ART UNIT	PAPER NUMBER
	,		2828	
•			DATE MAILED: 07/16/2003	

Please find below and/or attached an Office communication concerning this application or proceeding.

		<u></u>				
	Application No.	Applicant(s)				
	09/993,824	WITTMAN ET AL.				
Office Action Summary	Examiner	Art Unit				
	Dung (Michael) T Nguyen	2828				
Th MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute. - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b). Status	36(a). In no event, however, may a reply be to y within the statutory minimum of thirty (30) do vill apply and will expire SIX (6) MONTHS fro , cause the application to become ABANDON	timely filed ays will be considered timely. m the mailing date of this communication. IED (35 U.S.C. § 133).				
1) Responsive to communication(s) filed on 16.	<u>lune 2003</u> .					
2a) This action is FINAL . 2b) ☐ Th	is action is non-final.					
3) Since this application is in condition for allowa closed in accordance with the practice under						
Disposition of Claims						
4) Claim(s) 15-23 and 25-30 is/are pending in the	• •					
4a) Of the above claim(s) is/are withdrav	wn from consideration.	4				
5) Claim(s) is/are allowed.						
Old Claim(s) 10-25 unit 20 50 Israe rejected.						
7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/o	r election requirement	SUPERVISORY PATENT EXAMINER				
8) Claim(s) are subject to restriction and/o	r election requirement.	TECHNOLOGY CENTER 2800				
9) The specification is objected to by the Examine	r.					
10)☐ The drawing(s) filed on is/are: a)☐ accept		aminer.				
Applicant may not request that any objection to the						
11) The proposed drawing correction filed on is: a) approved b) disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12)☐ The oath or declaration is objected to by the Ex	aminer.					
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) ☐ All b) ☐ Some * c) ☐ None of:	•					
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents	2. Certified copies of the priority documents have been received in Application No					
 3. Copies of the certified copies of the prior application from the International Bu * See the attached detailed Office action for a list 	reau (PCT Rule 17.2(a)).					
14) Acknowledgment is made of a claim for domesti	·-					
a) The translation of the foreign language pro 15) Acknowledgment is made of a claim for domesti	visional application has been re	eceived.				
Attachment(s)	, , , == ==============================					
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informa	ary (PTO-413) Paper No(s) Il Patent Application (PTO-152)				

7/11/03

Application/Control Number: 09/993,824

Art Unit: 2828

DETAILED ACTION

In response to the communications dated 01/13/03 through 06/16/03, claims 15-30 are pending in this application.

Allowable Subject Matter

The indicated allowability of claims 18 and 27 are withdrawn in view of the newly discovered reference(s) to Kumar et al. (US 6,541,164). Rejections based on the newly cited reference(s) follow. Applicant's argument is in most in view of the new ground of rejection.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 15-23, and 25-30 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ueno et al. (US 6,285,700) (herein after Ueno) in view of Kumar et al. (US 6,541,164) (herein after Kumar).

Application/Control Number: 09/993,824

Art Unit: 2828

With respect to claims 15-16, 19-21, 23, and 26-30, Ueno show in Fig.7 an AlGaAs semiconductor laser emitting at a given wavelength and having an emission facet with a coating layer 1 of a predetermined reflectivity, wherein the coating layer is homogeneous and of a preselected thickness (col.11, 1.25-31 and 60-66, TABLE 1). Ueno do not disclose the PE-CVD process and the coating layer comprising SiON:H. However, Kumar teaches a PE-CVD process (col.9, line 16), and SiONH (col. 9, line 5). For the benefit of manufacturing a semiconductor laser coating layer, it would have been obvious to one having ordinary skill in the art at the time the invention was made to provide Ueno the PE-CVD process and SiONH as taught by Kumar.

With respect to claims 17 and 25, Ueno disclose a SiON coating layer refraction index of 1.46-1.96 (1.96 met the claim limitation of at least 1.83) (col.12, table 1) for an AlGaAs laser.

With respect to claim 22, Ueno show in Fig.3B a coupling of the standing wave between the semiconductor body and the coating layer occurs at the minimum of the standing wave.

With respect to claim 18, Kumar disclose Si.sub3.N.sub4 (col. 9, line 37).

Citation of The Pertinent References

The following US patents are being made of record, even though they were not relied upon in this Office action, for being similar in subject matter, and may be relied upon in any future Office Actions: USPN 6380611.

Art Unit: 2828

Communication Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dung (Michael) T Nguyen whose telephone number is (703) 305-7159. The examiner can normally be reached on 8:30 - 17:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Paul Ip can be reached on (703) 308-3098. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 306-5511 for regular communications and (703) 306-5511 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 306-3329.

Nguyen (Michael) Dung July 10, 2003 PAUL IP SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800

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